

Attorney Docket: 071469-0306881
Client Reference: ES-016

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of:

BALASUBRAMANIAM et al.

Confirmation Number: 4465

Application No.: 10/743,275

Group Art Unit: 2813

Filed: December 23, 2003

Examiner: NGUYEN, Tranh T.

Title: METHOD FOR REMOVING PHOTORESIST FROM A SUBSTRATE AND
METHOD OF FORMING A FEATURE IN A DIELECTRIC LAYER ON A
SUBSTRATE (Amended)

AMENDMENT

Mail Stop Amendment
United States Patent and Trademark Office
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Randolph Building
401 Dulany Street
Alexandria, VA 22314

Sir:

In response to the Office Action dated September 6, 2005, the due date for which is extended by the attached Petition for a Three Month Extension of Time and requisite fee, please amend the above-identified application as follows: